

Universidade Federal de Pernambuco

CTG – Centro de tecnologia e geociências
DES – Departamento de Eletrônica e Sistemas

Introdução aos Dispositivos Semicondutores

Professor : Joaquim F Martins Filho

Monitor : Daniel Marinho e Silva

FORMULÁRIO – 2ª. Unidade

Transistor Bipolar de junção (TBJ)

$$I_E = I_C + I_B$$

$$I_C = B \cdot I_{E_P}$$

$$I_{E_P} = \gamma \cdot I_E$$

$$I_C = \alpha \cdot I_E$$

$$I_C = \beta \cdot I_B$$

$$\gamma = \left[1 + \left(\frac{D_{nE} \cdot N_d \cdot L_p}{D_p \cdot N_a \cdot L_{nE}} \cdot \tanh\left(\frac{l}{L_p}\right) \right) \right]^{-1} \quad B = \operatorname{sech}\left(\frac{l}{L_p}\right)$$

$$\alpha = \left\{ \cosh\left(\frac{l}{L_p}\right) + \left[\frac{D_{nE} \cdot N_d \cdot L_p}{D_p \cdot N_a \cdot L_{nE}} \cdot \operatorname{senh}\left(\frac{l}{L_p}\right) \right] \right\}^{-1}$$

$$\beta = \left\{ \cosh\left(\frac{l}{L_p}\right) + \left[\frac{D_{nE} \cdot N_d \cdot L_p}{D_p \cdot N_a \cdot L_{nE}} \cdot \operatorname{senh}\left(\frac{l}{L_p}\right) \right] - 1 \right\}^{-1}$$

$$I_E = I_{ES} \left(e^{\frac{eV_{EB}}{k_B T}} - 1 \right) - \alpha_I \cdot I_{CS} \left(e^{\frac{eV_{CB}}{k_B T}} - 1 \right)$$

$$I_C = \alpha_N \cdot I_{ES} \left(e^{\frac{eV_{EB}}{k_B T}} - 1 \right) - I_{CS} \left(e^{\frac{eV_{CB}}{k_B T}} - 1 \right)$$

$$I_{ES} = \frac{e \cdot A \cdot D_p \cdot p_B}{L_p} \cdot \operatorname{coth}\left(\frac{l}{L_p}\right) + \frac{e \cdot A \cdot D_{nE} \cdot n_E}{L_{nE}}$$

$$I_{CS} = \frac{e \cdot A \cdot D_p \cdot p_B}{L_p} \cdot \operatorname{coth}\left(\frac{l}{L_p}\right) + \frac{e \cdot A \cdot D_{nC} \cdot n_C}{L_{nC}}$$

$$\alpha_N = \frac{e \cdot A \cdot D_p \cdot p_B}{I_{ES} \cdot L_p} \cdot \operatorname{csch}\left(\frac{l}{L_p}\right)$$

$$\alpha_I = \frac{e \cdot A \cdot D_p \cdot p_B}{I_{CS} \cdot L_p} \cdot \operatorname{csch}\left(\frac{l}{L_p}\right)$$

$$\alpha_N \cdot I_{ES} = \alpha_I \cdot I_{CS}$$

Transistor Efeito de campo - Junção (JFET)

$$V_C = \frac{e.N_d.a^2}{2\epsilon}$$

$$|I_D| = G_0.V_C \cdot \left[\frac{V_D}{V_C} + \frac{2}{3} \left(\frac{-V_p}{V_C} \right)^{\frac{3}{2}} - \frac{2}{3} \left(\frac{V_D - V_p}{V_C} \right)^{\frac{3}{2}} \right]$$

$$G_0 = \frac{2e.N_d.\mu_n.D.a}{L}$$

$$V_{Dsat} = V_c + V_p$$

Transistor Efeito de campo – MOS (MOSFET)

$$V_C = \frac{Q_d - Q_{ox}}{C_i} + 2\phi_F + \phi_{ms}$$

$$2\phi_F = \frac{2K_B T}{e} \ln \left(\frac{N_a}{n_i} \right)$$

$$Q_d = 2(\epsilon_s . e . N_a . \phi_F)^{\frac{1}{2}} . A$$

$$C_i = \frac{\epsilon_i . A}{d}$$

$$I_{Dsat} = \frac{\mu_n . C_i . V_{DS}^2}{2L^2}$$

$$I_D = \frac{\mu_n . C_i}{L^2} \cdot \left[(V_p - V_C)V_D - \frac{V_D^2}{2} \right]$$

Dispositivos opto-eletrônicos

$$I = I_0 . e^{-\alpha x}$$

$$\alpha = \frac{2\omega\kappa}{c}$$

$$N = n + iK$$

$$R = \left| \frac{(N - 1)^2}{N + 1} \right|$$

$$g = \frac{\eta . I_0}{\hbar . \omega . d}$$

$$\Delta I = \frac{b . d . g . \tau_r . e . (\mu_n + \mu_p) V}{l}$$

$$G = \frac{\Delta I}{e . g . b . d . l}$$

$$I = I_S \cdot \left(e^{\frac{eV}{K_B T}} - 1 \right) - I_L$$

$$I_L = \frac{\eta . e . I_0 . A}{\hbar . \omega} = \frac{\eta . e . P_L . \lambda}{hc}$$

$$P_L = I . A$$

$$FF = \frac{I_m . V_m}{I_{cc} . V_{ca}}$$

$$r = \frac{I_L}{P_L} = \frac{\eta . e . \lambda}{hc}$$

$$\eta_{conv} = \frac{P_{ele}}{P_L} = \frac{I_m . V_m}{P_L}$$